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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/501,791	07/02/2004	Yoshifumi Kachi	039.0026	6914
	7590 05/09/200 RAKAMI IP ASSOCIA	EXAMINER		
	LDING, 7TH FLOOR	CHANDRA, SATISH		
6-8 NISHITEMMA 2-CHOME, KITA-KU OSAKA-SHI, 530-0047		A-KU	ART UNIT	PAPER NUMBER
JAPAN			1763	
				DEL 11/EDY 140DE
			MAIL DATE	DELIVERY MODE
			05/09/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

<u> </u>		Application No.	Applicant(s)				
Office Action Summary		10/501,791	KACHI ET AL.				
		Examiner	Art Unit				
		Satish Chandra	1763				
	AILING DATE of this communication app	ears on the cover sheet wi	th the correspondence add	lress			
	Period for Reply						
WHICHEVER - Extensions of tin after SIX (6) MC - If NO period for - Failure to reply Any reply receiv	ED STATUTORY PERIOD FOR REPLY R IS LONGER, FROM THE MAILING DA me may be available under the provisions of 37 CFR 1.13 DNTHS from the mailing date of this communication. reply is specified above, the maximum statutory period we within the set or extended period for reply will, by statute, red by the Office later than three months after the mailing term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNIC (6(a). In no event, however, may a re ill apply and will expire SIX (6) MON' cause the application to become AB	CATION. Sply be timely filed THS from the mailing date of this con ANDONED (35 U.S.C. § 133).				
Status	•		•				
1)⊠ Respor	nsive to communication(s) filed on <u>19 M</u>	arch 2007.					
	This action is FINAL . 2b) ☐ This action is non-final.						
3)☐ Since t	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of C	Claims	•					
4) Claim(s	s) <u>1 - 14</u> is/are pending in the application	1.					
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.						
6)⊠ Claim(6)⊠ Claim(s) <u>1 - 14</u> is/are rejected.						
• • •	s) is/are objected to.						
8)☐ Claim(s) are subject to restriction and/o	r election requirement.					
Application Pap	ers		÷				
9)∐ The spe	ecification is objected to by the Examine	r.					
10)⊠ The drawing(s) filed on <u>02 July 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
• •	nt may not request that any objection to the						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 3	5 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)⊠ All b)□ Some * c)□ None of:							
1.⊠ Certified copies of the priority documents have been received.							
2. Certified copies of the priority documents have been received in Application No							
3. Copies of the certified copies of the priority documents have been received in this National Stage							
application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.							
AM							
Attachment(s) 1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)							
	tsperson's Patent Drawing Review (PTO-948)	Paper No(s	s)/Mail Date				
	sclosure Statement(s) (PTO/SB/08) fail Date	5)	nformal Patent Application				
. apo. 140(3)/14		-, <u> </u>					

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1 - 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kuibira et al (Patent No. 6,508,884) in view of Aonuma et al (Patent No. JP02002252269)

The applied reference has a common assignee with the instant application. Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art only under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 103(a) might be overcome by: (1) a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not an invention "by another"; (2) a showing of a date of invention for the claimed subject matter of the application which corresponds to subject matter disclosed but not claimed in the reference, prior to the effective U.S. filing date of the reference under 37 CFR 1.131; or (3) an oath or declaration under 37 CFR 1.130 stating that the application and reference are currently owned by the same party and that the inventor named in the application is the prior inventor under 35 U.S.C. 104, together with a terminal disclaimer in accordance with 37 CFR 1.321(c). This rejection might also be

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overcome by showing that the reference is disqualified under 35 U.S.C. 103(c) as prior art in a rejection under 35 U.S.C. 103(a). See MPEP § 706.02(I)(1) and § 706.02(I)(2).

Kuibira et al discloses:

Regarding claim 1, a wafer holder (susceptor) 1 (Fig 5) containing at least one heater 11.

The cross sectional shape 11 (Fig 3) is shown as a rectangular whose lateral and bottom sides perpendicular to each other and having an angle of 90 degrees.

Regarding claims 2, 3, the temperature distribution of the wafer in a film deposition process should be within 1% (Column 4, lines 66-67; Column 5, lines 1-2) when the line width and the line interval of the linear pattern of the conductive layer (Column 1, lines 57-60) are each 5 mm or less. And in order to achieve a temperature distribution within 0.5%, the line width and the line interval of the linear pattern of the conductive layer should be 1 mm or less (Column 5, lines 3-4).

Regarding claims 4, 8 and 9, any one of aluminum nitride, aluminum oxide, silicon nitride and aluminum oxynitride (Column 5, lines 15-18) as base material for the wafer holder.

Regarding claims 5 and 10, the use of aluminum nitride for ceramic substrate having a high thermal conductivity of at least 100 W/m K (Column 5, lines 25-26).

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Regarding claims 6, 11, using at least one metal from the group tungsten, molybdenum, silver, palladium, platinum, nickel or chromium (Column 5, lines 31,32) for forming the conductive layer.

Regarding claim 7, 12-14, using plasma electrode 12 (Fig 5) as a conductive layer (column 4, lines 5-6).

Kuibira et al does not disclose:

Regarding claim 1, a resistive heating element composed of wiring lines, the wiring lines being substantially trapezoidal in cross-section.

Aonuma et al discloses:

Regarding claim 1, a susceptor including a heating element 12 (Fig 2) embedded therein. The resistive heating element may be oval, capsular or rectangular and is not limited in its cross-sectional shape (Para 0024).

Therefore it would have been obvious to one of ordinary skill in the art to provide resistive heating elements of any shape including trapezoidal having inclined edges in the apparatus of Kuibira et al as taught by Aonuma et al.

The motivation to provide a trapezoidal shaped heating element having inclined edges is to provide an alternate and equivalent heating element as taught by Aonuma et al. Further, it was held in *re Dailey, 357 F.2d 669, 149 USPQ 47 (CCPA 1966)* that the shape was a matter of choice which a person of ordinary skill in the art would have found obvious absent persuasive evidence that the particular shape was significant. (Also see MPEP 2144.04(d)).

Response to Arguments

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Applicant's arguments with respect to claims 1 - 14 have been considered but are most in view of the new ground(s) of rejection.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Satish Chandra whose telephone number is 571-272-3769. The examiner can normally be reached on 8 a.m. - 4:30 p.m..

If attempts to reach the examiner by telephone are unsuccessful, Primary Examiner, Jeffrie R. Lund can be reached on 571-272-1437. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pairdirect.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (tollfree). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

5 m Choul Satish Chandra

Primary Examiner

SC 3/25/2007